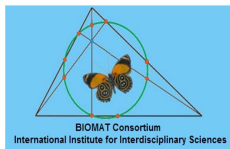


A new numerical approach for simulation of pattern formation models on stationary and growing surfaces

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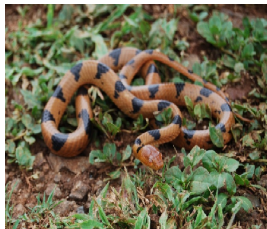
November 4, 2013



- Motivation
- Schnakenberg model
- Triangulation and implementation
- Examples on growing manifolds
- Role of eigenfunction in pattern evolution
- Conclusion



Pattern formation on a evolving biological surface modelled by reaction-diffusion equation.



Let M be two dimensional manifold and $u : M \rightarrow \mathbb{R}^2$. The model is given by

$$\partial_t u_1 - d_1 \Delta_M u_1 = \gamma(a - u_1 + u_1^2 u_2) = \gamma f_1(u)$$

$$\partial_t u_2 - d_2 \Delta_M u_2 = \gamma(b - u_1^2 u_2) = \gamma f_2(u)$$

where d_j , a , b and γ are some positive constants.

The stationary problem

$$\begin{aligned} -d_1 \Delta_M u_1 &= \gamma(a - u_1 + u_1^2 u_2) \\ -d_2 \Delta_M u_2 &= \gamma(b - u_1^2 u_2) \end{aligned}$$

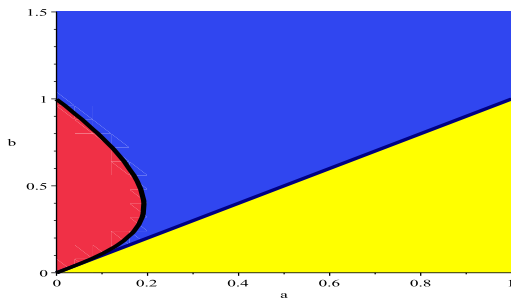
The constant (positive) solution is

$$u = \left(a + b, \frac{b}{(a + b)^2} \right)$$



To get diffusion-driven instability, choose a and b such that

$$(a + b)^3 + a - b > 0 \quad \text{and} \quad a < b$$



and diffusion parameters such that

$$\sqrt{\frac{d_2}{d_1}} > \frac{(a+b)(a+b+\sqrt{2b(a+b)})}{b-a}$$

In particular $d_2 > d_1$.



To solve model on the sphere S^2 with metric g , let V_h be some finite dimensional subspace of $H^1(S^2)$ and let

$$V_h = \text{span}(\psi_1, \dots, \psi_m)$$

The approximate solution $u = (u_1, u_2)$ can be written as

$$u_j(x, t) = \sum_{i=1}^m c_i^j(t) \psi_i(x)$$



Find (u_1, u_2) such that

$$\partial_t \int_{S^2} u_1 \psi_j \omega_{S^2} + d_1 \int_{S^2} g(\text{grad}(u_1), \text{grad}(\psi_j)) \omega_{S^2} = \gamma \int_{S^2} f_1(u) \psi_j \omega_{S^2}$$

$$\partial_t \int_{S^2} u_2 \psi_j \omega_{S^2} + d_2 \int_{S^2} g(\text{grad}(u_2), \text{grad}(\psi_j)) \omega_{S^2} = \gamma \int_{S^2} f_2(u) \psi_j \omega_{S^2}$$

where ω_{S^2} is the area form.

Let δt be the time step and $c_i^{j,n} = c_i^j(n\delta t)$ and

$$u_j^n = \sum_{i=1}^m c_i^{j,n} \psi_i \approx u_j(x, n\delta t)$$

using implicit Euler method for time discretization

$$\begin{aligned} ((1 + \delta t \gamma)M^{n+1} + \delta t d_1 R^{n+1} - \delta t \gamma \tilde{M}^n) c^{1,n+1} &= M^n c^{1,n} + \delta t \gamma a F^{n+1} \\ (M^{n+1} + \delta t d_2 R^{n+1} + \delta t \gamma \hat{M}^n) c^{2,n+1} &= M^n c^{2,n} + \delta t \gamma b F^{n+1} \end{aligned}$$

where

$$M_{ij}^n = \int_{S^2} \psi_i \psi_j \omega_{S^2}^n$$

$$R_{ij}^n = \int_{S^2} g(\text{grad}(\psi_i), \text{grad}(\psi_j)) \omega_{S^2}^n$$

$$E_{ijkl}^n = \int_{S^2} \psi_i \psi_j \psi_k \psi_l \omega_{S^2}^n$$

$$F_i^n = \int_{S^2} \psi_i \omega_{S^2}^n$$

$$\tilde{M}_{ij}^n = \sum_{k,\ell} E_{ijkl}^{n+1} c_k^{1,n} c_\ell^{2,n}$$

$$\hat{M}_{ij}^n = \sum_{k,\ell} E_{ijkl}^{n+1} c_k^{1,n} c_\ell^{1,n}$$

The sphere S^2 is covered with 6 patches D_j

$$D_1 = (-1, 1) \times (-1, 1) \quad \varphi_1(z) = \gamma_1^{-\frac{1}{2}} \begin{pmatrix} z_1 \\ z_2 \\ 1 \end{pmatrix}$$

$$D_2 = (1, 3) \times (-1, 1) \quad \varphi_2(z) = \gamma_2^{-\frac{1}{2}} \begin{pmatrix} 1 \\ z_2 \\ 2 - z_1 \end{pmatrix}$$

$$D_3 = (-1, 1) \times (1, 3) \quad \varphi_3(z) = \gamma_3^{-\frac{1}{2}} \begin{pmatrix} z_1 \\ 1 \\ 2 - z_2 \end{pmatrix}$$

$$D_{j+3} = D_j$$

$$\varphi_{j+3} = -\varphi_j$$

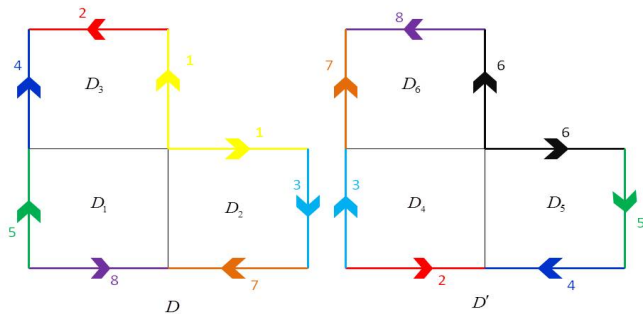
where

$$\gamma_1 = 1 + |z|^2 \quad , \quad \gamma_2 = 1 + (z_1 - 2)^2 + z_2^2 \quad , \quad \gamma_3 = 1 + z_1^2 + (z_2 - 2)^2$$

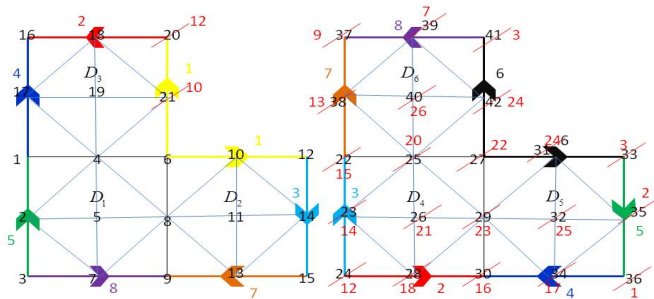
Hence $\varphi_j : D_j \rightarrow S^2$



Identification



Identification



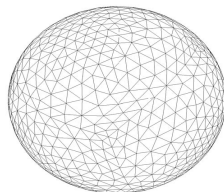
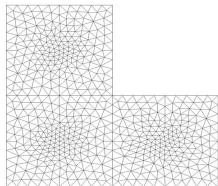
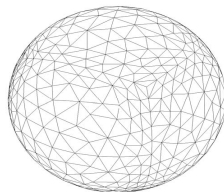
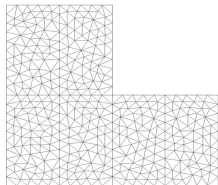
A:

1	2	3	4	...	19	10	12	15	14	...	26	3	24
1	2	3	4	...	19	20	21	22	23	...	40	41	42

Using Riemannian metric $G_j = d\varphi_j^T d\varphi_j$ in triangulation



Triangulation



The growing manifold is topologically the sphere S^2 with changing Riemannian metric.

To produce the growing manifold, define $\beta : S^2 \rightarrow \mathbb{R}^3$ and $\hat{\varphi}_j = \beta \circ \varphi_j$ then the Riemannian metric is

$$\hat{G}_j = d\hat{\varphi}_j^T d\hat{\varphi}_j = d\varphi_j^T d\beta^T d\beta d\varphi_j$$



Growing sphere (Isotropic grow)

Let $\beta(x) = \rho(t)(x_1, x_2, x_3)$ where

$$\rho(t) = \frac{e^{rt}}{1 + \frac{1}{K}(e^{rt} - 1)}$$

Then $\hat{\varphi}_j = \rho(t)\varphi_j$ and the corresponding Riemannian metric is $\hat{G}_j = \rho(t)^2 G_j$



Growing sphere (Isotropic grow)

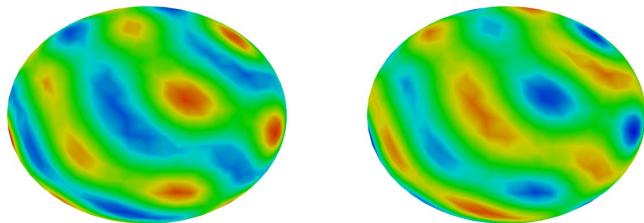
choosing parameters as follows

d_1	d_2	γ	a	b	K	r	δt
1	10	200	0.1	0.9	1.5	0.1	0.01



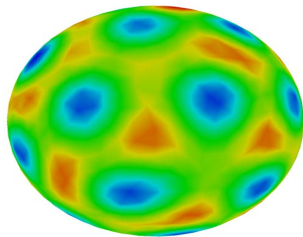
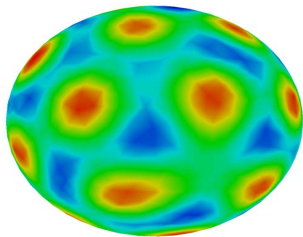
Growing sphere (Isotropic grow)

The concentrations u_1 and u_2 at $t = 5$



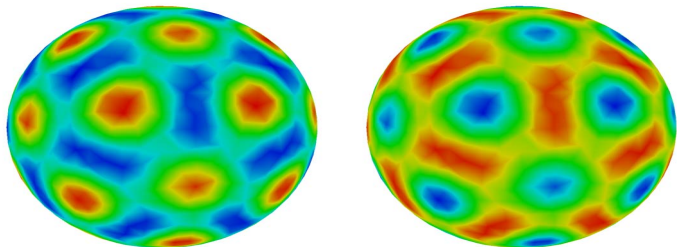
Growing sphere (Isotropic grow)

The concentrations u_1 and u_2 at $t = 10$



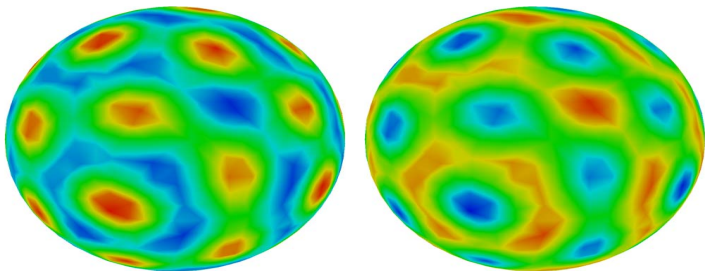
Growing sphere (Isotropic grow)

The concentrations u_1 and u_2 at $t = 20$



Growing sphere (Isotropic grow)

The concentrations u_1 and u_2 at $t = 50$



Evolving sphere (Anisotropic grow)

Define

$$\beta(x) = (lx_1, lx_2, (lx_3/h)^{1/2p})$$

such that

$$\begin{cases} h(t) = \frac{l(t)}{q(t)^{2p}} \\ q(t) = \frac{q_0}{\beta + (1-\beta)e^{-rt}} \\ l(t) = l_0(1 + \alpha(1 - e^{-kt})) \end{cases}$$



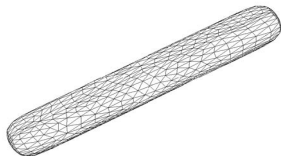
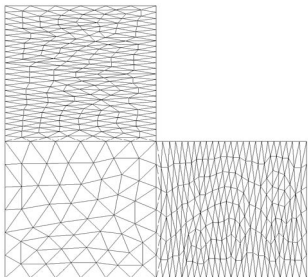
Evolving sphere (Anisotropic grow)

Choose parameters as

d_1	d_2	γ	a	b	q_0	l_0	α	β	r	k	p
1	100	500	0.1	0.9	0.5	0.1	0.8	0.3	0.5	0.5	5

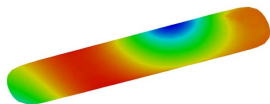
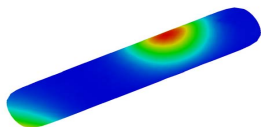


Evolving sphere (Anisotropic grow)



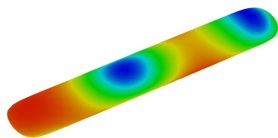
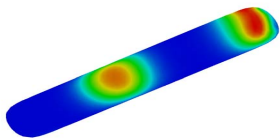
Evolving sphere (Anisotropic grow)

The concentrations u_1 and u_2 at $t = 0.1$ with $\delta t = 0.0005$



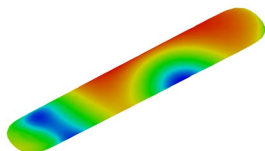
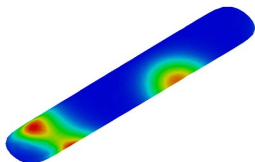
Evolving sphere (Anisotropic grow)

The concentrations u_1 and u_2 at $t = 1.6$ with $\delta t = 0.0005$



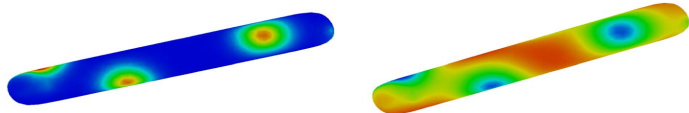
Evolving sphere (Anisotropic grow)

The concentrations u_1 and u_2 at $t = 1.68$ with $\delta t = 0.0005$



Evolving sphere (Anisotropic grow)

The concentrations u_1 and u_2 at $t = 2.75$ with $\delta t = 0.0005$



Eigenfunctions role in pattern formation

y_1 and y_2 are two positive roots of

$$p_0(y) = d_1 d_2 (a + b) y^2 + \left((a + b)^3 d_1 + (a - b) d_2 \right) y + (a + b)^3$$

Then we call $I = (y_1, y_2)$ critical interval.

Let λ be an eigenvalue of $-\Delta$ and v_λ be the corresponding eigenfunction.

If $\lambda/\gamma \in (y_1, y_2)$ then the linearized Schnackenberg problem has a solution of form $C v_\lambda e^{\mu\gamma t}$ where μ is the positive solution of

$$p_1(\mu, \lambda) = (a + b) \mu^2 + \left((d_1 + d_2)(a + b) \lambda + (a + b)^3 + a - b \right) \mu + p_0(\lambda)$$



Choosing parameters as follows

d_1	d_2	a	b
1	10	0.1	0.9

The computed critical interval is $I = [0.2, 0.5]$.

Eigenfunction and pattern formation

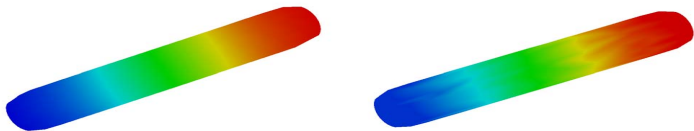
Let $t = 1.6$ be the ending time.

$\lambda_1 = 3.64$ and $\lambda_2 = 14.76$ are two first eigenvalues.

Set $\gamma = 15$ then just $\lambda_1/\gamma \in I = [0.2, 0.5]$.



The eigenfunction and concentration u_1



Changing the parameter as follows

d_1	d_2	a	b
1	20	0.2	1

The computed critical interval is $I = [0.169, 0.425]$.

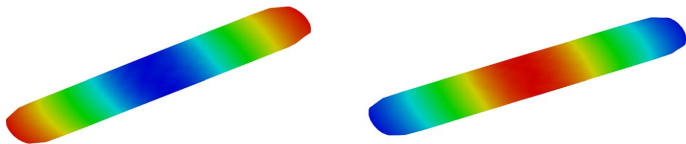
Eigenfunction and pattern formation

The ending time $t = 1.6$ and $\lambda_3 = 15.01$.

Set $\gamma = 72$ then $\lambda_3/\gamma \in I$.



The eigenfunction and concentration u_1



- Our approach can also readily be extended to more complicated surfaces.
- Since all computations are done in two dimensional domains there is no error related to the approximation of the surface in three dimensional space.
- In the case of restricting the parameters such that one eigenvalue of Laplace operator belongs to the critical interval, we are able to predict sort of pattern formation.
- The method benefits from simplicity in programming for different kinds of curved surfaces.

Question?

Thanks for your attention